

oalgraia!

(b) Amendment to the Claims

Please cancel claims 6, 8, 12-14, 20, 22 and 26-30 without prejudice or disclaimer of subject matter.

Kindly amend claims 1, 10, 11, 15, 24 and 25 as follows. A detailed listing of all the claims is provided.

- 1. (Currently Amended) An exhaust processing method of exhausting a processing space for subjecting a substrate or a film to plasma processing with plasma, which comprises:
- (a) providing <u>a</u> chemical-reaction inducing <u>unit</u>means having a heating element comprising a first metal member in an exhaust line, said exhaust line connecting the processing space and an exhaust <u>unit</u>means for exhausting the processing space, wherein the first metal member is connected to a power source;
- (b) providing a plasma blocking unitmeans consisting of a second metal member electrically grounded between the processing space and the first metal member; wherein the chemical-reaction inducing unit is provided at a position where the plasma reaches and the plasma blocking unit blocks the plasma from reaching the chemical-reaction inducing unit; and
- (c) causing chemical reaction of at least either an unreacted gas or a byproduct exhausted from the processing space via heat from said heating element while
 blocking plasma in the processing space from reaching the chemical-reaction inducing
 means via said plasma blocking means unit acts to reduce electron number density in the
 plasma reaching the chemical-reaction inducing unit by at least 90%.